

**AMENDMENT UNDER 37 C.F.R. § 1.114(c)  
GROUP 1791  
PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q76587

Kouji TAKAHASHI, et al.

Appln. No.: 10/619,181

Group Art Unit: 1791

Confirmation No.: 4972

Examiner: Jason L LAZORCIK

Filed: July 15, 2003

For: GLASS SUBSTRATE FOR A MASK BLANK, METHOD OF PRODUCING A GLASS  
SUBSTRATE FOR A MASK BLANK, MASK BLANK, METHOD OF PRODUCING  
THE MASK BLANK, TRANSFER MASK, AND METHOD OF PRODUCING A  
TRANSFER MASK

**AMENDMENT UNDER 37 C.F.R. § 1.114(c)**

**MAIL STOP AF**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the final Office Action dated October 7, 2008, and in connection with the filing of an accompanying RCE, please amend the above-identified application as follows on the accompanying pages.

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